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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/822,335	04/02/2001	Paul Enquist	205109US20	9790	
22850	7590 08/13/2003				
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.			EXAMINER		
1940 DUKE S ALEXANDR	IA, VA 22314	NGO, NGAN V			
			ART UNIT	PAPER NUMBER	
			2814		
				DATE MAILED: 08/13/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)	
0.00	4-11	09/822,335	ENQUIST, PAUL	
Offic	Action Summary	Examiner	Art Unit	
		Ngan Ngo	2814	
` The MA Period for Reply	ILING DATE of this communication	appears on the cover sl	et with the correspondence ac	Idress
THE MAILING - Extensions of time after SIX (6) MON - If the period for re - If NO period for re - Failure to reply wit - Any reply received	D STATUTORY PERIOD FOR R DATE OF THIS COMMUNICATION of 37 CIPS from the mailing date of this communication of specified above is less than thirty (30) days, ply is specified above, the maximum statutory phin the set or extended period for reply will, by the Office later than three months after the adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no event, however n. a reply within the statutory minimu eriod will apply and will expire SIX statute, cause the application to be	, may a reply be timely filed m of thirty (30) days will be considered time (6) MONTHS from the mailing date of this come ABANDONED (35 U.S.C. § 133).	
1)⊠ Respon	sive to communication(s) filed on	<u>24 July 2003</u> .		
2a)☐ This act	ion is FINAL. 2b)⊠	This action is non-fina	l.	
3)☐ Since the closed i	nis application is in condition for a n accordance with the practice u	llowance except for form nder <i>Ex parte Quayle</i> , 19	nal matters, prosecution as to th 935 C.D. 11, 453 O.G. 213.	ne merits is
Disposition of Cla			Ž	
	40-47,49,50 and 52-78 is/are pe	20 °		
4a) Of the	e above claim(s) is/are wit	hdrawn from considerati	o n	
•	is/are allowed.			
6)⊠ Claim(s)	40-47,49,50 and 52-78 is/are rej	ected		
•	is/are objected to.			
8) ☐ Claim(s) Application Pape	are subject to restriction a	ind/or election requireme	ent.	
9)∐ The spec	ification is objected to by the Exa	miner.		
10)□ The draw	ing(s) filed on is/are: a)□	accepted or b)⊡ objected	to by the Examiner.	
, ,	nt may not request that any objection			
11)☐ The prop	osed drawing correction filed on _	is: a) approved	b) disapproved by the Examir	ner.
	ved, corrected drawings are required	•	n.	
12)∐ The oath	or declaration is objected to by th	e Examiner.		
Priority under 35	U.S.C. §§ 119 and 120			
13)☐ Acknowl	edgment is made of a claim for fo	reign priority under 35 L	J.S.C. § 119(a)-(d) or (f).	
a) ☐ All b)	☐ Some * c)☐ None of:			
	ertified copies of the priority docu	•	•	
	ertified copies of the phority docu		was a	
	opies of the certified copies of the application from the Internation ttached detailed Office action for	al Bureau (PCT Rule 17	.2(a)).	l Stage
14) ☐ Acknowled	dgment is made of a claim for do	mestic priority under 35	J. C. § 119(e) (to a provisiona	al application).
	translation of the foreign languag dgment is made of a claim for do			
Attachment(s)				
Notice of Refere Notice of Draftsp	nces Cited (PTO-892) person's Patent Drawing Review (PTO-94 losure Statement(s) (PTO-1449) Paper N	8) 5) 🔲 N	nterview Summary (PTO-413) Paper No otice of Informal Patent Application (P ther:	
U.S. Patent and Trademark Offic PTO-326 (Rev. 04-01)		ce Action Summary	Part of Paper No. 17	

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The amendment filed May 21, 2003 has been entered and made of record as paper no. 14.

Claims 40-47, 49-50 and 52-76 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Enquist et al (US-5,318,916, cited by Applicant).

Enquist discloses a semiconductor device comprising a first active region (70), a second active region (101), a third active region (12), first, second, and third contacts (90, 31, and 80). Enquist teaches that the first and second active regions are symmetrically self-aligned.

Claims 40-47, 49-50 and 52-78 are alternatively rejected under 35 U.S.C. 103(a) as being unpatentable over Nii (US-5,247,192).

Nii discloses a semiconductor dev e comprising a rest active region (2), a second active region (4), a third active region (3), and first, second and third contacts (1, 9, and 6). It would have been obvious that the first active region and second active region are symmetrically aligned because the opening in layers 5, 6, and 7 are formed by the same mask. No patentable weight is given to the term "self-aligned" because it is a process limitation. A "product by process" claim is directed to the product per se, no matter how actually made, In re Hirao, 190 USPQ 15 at 17 (footnote 3). See also In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324; In re Avery, 186 USPQ 161; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Marosi et al, 218 USPQ 289; and particularly In re Thorpe, 227 USPQ 964, all of which make it clear that it is the patentability of the final product per se

which must be determined in a "product by process" claim, and not the patentability of the process, and that an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that applicant has the burden of proof in such cases, as the above caselaw makes clear.

Applicant's arguments filed May 2 \$2003 have been fully considered but they are not persuasive.

"symmetrically self-aligned" is process limitations. It is not a product limitation.

Applicant failed to show the difference in structure between Applicants' claims and the cited prior arts. All of the species shown in figures 1-18 are formed by self-aligned process but do not show a common structure that are formed by "self-aligned".

Therefore, "self-aligned" is process limitations, not product limitations. This subject matter was discussed several times in the parent applications.

Any inquiry concerning this communication should be directed to Examiner Ngan Ngo at telephone number (703) 308-4938. The fax number for the Art unit is (703) 308-7722.

Any inquiry of a general nature or relating to the starus of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956.

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Ngan Ngo

August 10, 2003

you I my

Ngan Van Ngo Primary Examiner